#2 TDS ATTORNE DE MINIO UCF-306CIP 4/3/02

IN THE UNITED STATES PATENT AND TRADEMARK OFFIC

In re Application of)	5 1
MARTIN RICHARDSON		
Serial No: TBA)	
Filed: Concurrently Herewith)	

For: EUV, XUV, AND X-RAY WAVELENGTH SOURCES CREATED FROM LASER PLASMA PRODUCED FROM LIQUID METAL SOLUTIONS, AND NANO-SIZE PARTICLES IN SOLUTIONS)

INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner of Patents and Trademarks Washington DC 20231

Sir:

Pursuant to the requirements of 37 CFR 1.97 and 1.98, Applicant hereby requests that the references listed in the attached form PTO-1449 be considered and made of record in the above-identified application.

Favorable consideration of the application at an early date is respectfully solicited.

Respectfully submitted,

By:

Brian S. Steinberger Attorney for Applicant Registration No. 36,423 101 Brevard Avenue Cocoa, FL 32922

Client no.: 23717

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